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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of: Tomoharu NAKANO et al.

Serial Number: Not yet assigned

(§371 of international application No. PCT/JP2004/006027)

Filed: October 5, 2005

For: POLISHING LIQUID FOR CMP PROCESS AND POLISHING

METHOD

Attorney Docket Number: 052463
Customer Number: 38834

INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents P. O. Box 1450 Alexandria, VA 22313-1450 October 5, 2005

Sir:

In compliance with 37 C.F.R. §1.56, Applicants direct the attention of the Patent and Trademark Office to the documents listed on the attached PTO/SB/08 and cited in the enclosed international search report. Since the documents were cited in the international search report, it is believed that copies of the documents have been transmitted by the International Bureau.

If there are any fees due in connection with the filing of this paper, please charge Deposit Account No. <u>50-2866</u>.

Respectfully submitted,

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Limited Recognition

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Enclosures: PTO/SB/08 and International Search Report

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| Combined Form PTO/SB/08A&B | Complete if Known | | |
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| Combined Form 1 10/35/00ACD | Application Number | New Application | |
| INFORMATION DISCLOSURE | Confirmation Number | | |
| STATEMENT BY APPLICANT | Filing Date | October 5, 2005 | |
| | First Named Inventor | Tomoharu NAKANO et al. | |
| (use as many sheets as necessary) | Art Unit | | |
| , | Examiner Name | | |
| Shoot 1 of 1 | Attorney Docket Number | 052463 | |

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| Γ | Examiner Initials* | Cite No.1 | Document Number | | Publication Date | | | |
| | | | Number | Kind Code ² (if known) | MM-DD-YYYY | Name of Patentee or Applicant of Cited Document | | |
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| | 2 | JP | 10-172935 | | 06-26-1998 | Fujimi, Inc. | |
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| NON PATENT LITERATURE DOCUMENTS | | | |
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| Examiner Cite Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazin journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city, and/or country where publisher. | | Translation ⁶ | |
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^{*}EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

¹Applicant's unique citation designation number (optional). ²See Kind Codes of USPTO Patent Documents at www.uspto.gov, MPEP 901.04 or in the comment box of this document. ³ Enter Office that issued the document, by the two-letter code (WIPO Standard ST. 3). ⁴For Japanese patent documents, the indication of the year of the reign of the Emperor must precede the serial number of the patent document. ⁵Kind of document by the appropriate symbols as indicated on the document under WIPO Standard ST. 16 if possible. ⁶ Applicant is to indicate here if English language Translation is attached.